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WHAT IS CLAIMED IS:

1. A method for forming a light emitting device, the method comprising:

providing a transparent substrate, on which substrate a transparent anode layer, a light emitting layer, a metal cathode layer are sequentially formed:

forming a sealant layer, at least covering the light emitting layer and the metal cathode layer;

providing a covering laver:

performing an evaporation depositing process, to forming an active absorption layer on the covering layer at a covering surface; and

putting the covering layer, by the covering surface, over at least a portion of the sealant layer above the metal cathode layer.

- 2. The method of claim 1, wherein before the step of performing the evaporation process, the method further comprises forming a recess region on the covering surface of the covering layer, whereby the active absorption layer is formed on a recessed surface of the recess region.
- 3. The method of claim 1, wherein in the step of providing the covering layer, the covering layer comprises a cap-like layer to completely cover over the sealant layer, the transparent anode layer, light emitting layer, and the metal cathode layer.
- 4. The method of claim 3, before the step of performing the evaporation depositing process, further comprising forming a recess region on the covering surface of the covering layer, whereby the active absorption layer is formed on a recessed surface of the recess region.
- The method of claim 3, wherein there is a clearance between the cap-like covering layer and the sealant layer.

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- The method of claim 1, wherein the metal cathode layer comprises one selected from the group consisting of Li, Mg, and Ca.
- The method of claim 1, the active absorption layer comprises one selected from the group consisting of Li, Mg, and Ca.
 - 8. A method form forming a light emitting device, the method comprising:

providing a transparent substrate, on which substrate a transparent anode layer, a light emitting layer, a metal cathode layer are sequentially formed;

performing an evaporation deposition process, to form an active absorption layer at least cover the metal cathode layer:

forming a sealant layer, at least covering the light emitting layer and the metal cathode layer:

providing a covering layer; and

putting the covering layer, by the covering surface, over at least a portion of the sealant layer above the metal cathode layer.

- The method of claim 8, wherein the metal cathode layer comprises one selected from the group consisting of Li, Mg, and Ca.
- 10. The method of claim 8, the active absorption layer comprises one selected from the group consisting of Li, Mg, and Ca.
- 11. A method for forming a light emitting device, the method comprising: providing a transparent substrate, on which substrate a transparent anode layer, a light emitting layer, a metal cathode layer are sequentially formed;

forming an insulating layer over the metal cathode layer;

forming a sealant layer, at least covering the insulating layer, the light emitting layer, the metal cathode layer, and the transparent anode layer;

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providing a covering layer; and

putting the covering layer on a portion of the sealant layer above the metal cathode layer.

- 12. The method of claim 11, wherein the metal cathode layer comprises one selected from the group consisting of Li, Mg, and Ca.
 - 13. The method of claim 11, the active absorption layer comprises one selected from the group consisting of Li, Mg, and Ca.
 - 14. A method for forming a light emitting device, the method comprising: providing a covering layer;

providing a light emitting unit, comprising a metal cathode layer;

performing an evaporation depositing process, to form an active absorption layer on a surface of the covering layer;

putting the covering layer with the surface having the active absorption layer, over at least a portion of the light emitting unit above the metal cathode layer.

- 15. The method of claim 14, wherein the metal cathode layer comprises one selected from the group consisting of Li, Mg, and Ca.
- 16. The method of claim 14, the active absorption layer comprises one selected from the group consisting of Li, Mg, and Ca.
 - 17. A method for forming a light emitting device, the method comprising:

providing a transparent substrate, on which substrate a transparent anode layer, a light emitting layer, a metal cathode layer are sequentially formed;

optionally forming a sealant layer, at least covering the metal cathode layer; providing a covering layer;

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etching the covering layer to form a recess region on the covering layer at a covering surface with respect to the metal cathode layer, and forming a trench enclosing the recess region:

performing an evaporation deposition process, to form an active absorption layer on the covering layer within the recess region;

coating a gluing layer on a portion of the covering layer between the trench and the recess region; and

adhering the covering layer onto the transparent substrate.

- 18. The method of claim 17, wherein the step of etching covering layer comprises performing a sand-jet etching process.
- 19. The method of claim 18, wherein the step of etching covering layer comprises performing a sand-jet etching process with etchant of aluminum oxide particles.
 - 20. A method for forming a light emitting device, the method comprising:

providing a transparent substrate, on which substrate a transparent anode layer, a light emitting layer, a metal cathode layer are sequentially formed;

optionally forming a sealant layer, at least covering the light emitting layer and the metal cathode layer;

providing a covering laver:

performing an evaporation deposition process, to form an active absorption layer on the covering layer within the recess region:

forming two frit lines on the covering layer, enclosing the active absorption layer, wherein a clearance between the two frit lines is reserved;

properly dripping a sealant material on the clearance; and

adhering the covering layer on the transparent substrate layer through the sealant material, wherein the active absorption layer is above the metal cathode layer.